Strain Compensation Thickness Calculator Distribution Notes

Stephen J. Polly *

Rochester Institute of Technology, Rochester, NY 14623

November 13, 2014

1 Introduction

This program calculates the required strain compensation (SC) thickness for quantum dots (QD) and their associated wetting layer (WL). It can also be used to calculate SC thickness for quantum wells (QW), or to calculate QD volume or effective QD material coverage based on QD properties.

2 License

This program is free software: you can redistribute it and/or modify it under the terms of the GNU General Public License as published by the Free Software Foundation, either version 3 of the License, or (at your option) any later version.

This program is distributed in the hope that it will be useful, but WITHOUT ANY WARRANTY; without even the implied warranty of MERCHANTABILITY or FITNESS FOR A PARTICULAR PURPOSE. See the GNU General Public License for more details.

You should have received a copy of the GNU General Public License along with this program. If not, see http://www.gnu.org/licenses/.

The source code for this program, as well as the most recent version of this document, is available at http://github.com/spolly/straincompensation.

3 Software Layout

The program is divided into four sections, with some attribution at the bottom. A screenshot of the program on startup is shown in Figure 1.

^{*}email: sjp5958@rit.edu

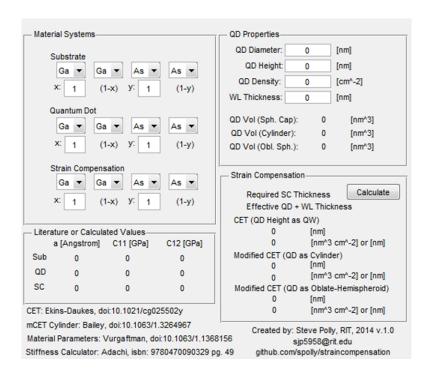


Figure 1: Screenshot of application straincompensation.m at startup.

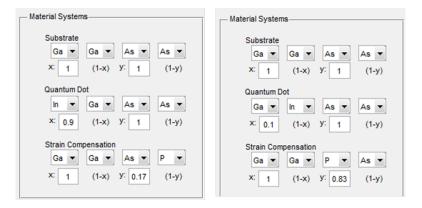


Figure 2: Screenshot of application showing two ways of selecting the same $In_{0.9}Ga_{0.1}As~QD$ and a $GaAs_{0.17}P_{0.83}$ strain compensation material systems.

3.1 Material Systems

Here the user selects the type and composition for the Substrate, Quantum Dot, and Strain Compensation material systems. All layers are set to GaAs by default. To select, for example, In_{0.9}Ga_{0.1}As QDs and a GaAs_{0.17}P_{0.83} strain compensation (SC) layer: the user would select as shown in Figure 2. Both methods of selecting material systems shown will produce the same results.

3.2 Literature or Calculated Values

This section shows the lattice constant and elastic stiffness constants for the substrate, QD, and SC materials selected in the Material System box. If the materials are binary (e.g.: GaAs, InAs, etc.) the material parameters are taken from Vurgaftman et al. [1]. If they are ternaries or quaternaries, these values are calculated via methods described in Sections 4.1 and 4.2 for lattice constant and elastic stiffness constant, respectively.

3.3 QD Properties

In this box, the user inputs QD parameters: QD Diameter [nm], QD Height [nm], QD Density [cm $^{-2}$], and WL Thickness [nm].

This box also displays the volume of a single QD in [nm³], based on the parameters entered, using three methods to define the QD shape: Spherical Cap, Cylinder, and Oblate-Hemispheroid. The first, QD Vol (Sph. Cap.) is shown here only for interest, and is not used anywhere else in the software. The other two volumes, QD Vol (Cylinder) and QD Vol (Obl. Sph.) are used in the calculation of necessary strain compensation material thicknesses using the respective Modified CET methods, described in Section 5. A comparison of these QD volume methods is discussed in Section 5.4.

3.4 Strain Compensation

This section shows the calculated required strain compensation material thickness based on the parameters entered in the other sections. It displays the resulting SC thicknesses, as well as effective thickness, or coverage, of the QD material. This is shown in [nm³ cm⁻²] but is effectively also in units [nm]. The methods used to calculate these thicknesses are discussed in Section 5.

4 Material Parameters

4.1 Lattice Constants

Lattice constants of binary compounds are taken from Vurgaftman et al. [1]. Linear interpolation of lattice constants is done using the appropriate versions of Vegard's Law, taken from Adachi [2] for ternary

$$a_{AB_xC_{1-x}} = x(a_{AB}) + (1-x)(a_{AC}) \tag{1}$$

and quaternary

$$a_{A_x B_{1-x} C_y D_{1-y}} = xy(a_{AC}) + x(1-y)(a_{AD}) + (1-x)y(a_{BC}) + (1-x)(1-y)(a_{BD})$$
(2)

material systems.

In Equations 1 and 2, a is the lattice constant, and the subscripts x and y denote the composition of the material. A and B represent group III elements while C and D are group V elements.

4.2 Elastic Stiffness Constants

Stiffness constants of binary compounds are taken from Vurgaftman *et al.* [1]. The constants of ternary and quaternary compounds are calculated using

$$ln(C_{ij}) = \alpha_{ij}ln(a) + \beta_{ij} \tag{3}$$

by Adachi relating C_{11} and C_{12} to the lattice constant by a fit against measured data of binary compounds [3, pp. 47-49]. Here C is the stiffness constant, while i and j are the indices of the stiffness tensor. α and β are coefficients extracted from a least-squares fit against experimental data.

The C_{11} and C_{12} fit Adachi uses includes experimental values of materials (such as BN) with smaller lattice constants than for typical III-V materials used in QD research and manufacturing. This work refit C_{11} and C_{12} only for compounds with Al, Ga, and In group III elements with P, As, and Sb group V elements. This reduced the R^2 error in matching the smaller subset of material systems used in this software. A comparison of Adachi's fit to the fit used here are shown in Figures 3 (C_{11}) and 4 (C_{12}). The coefficients from both Adachi and This Work are shown in Table 1.

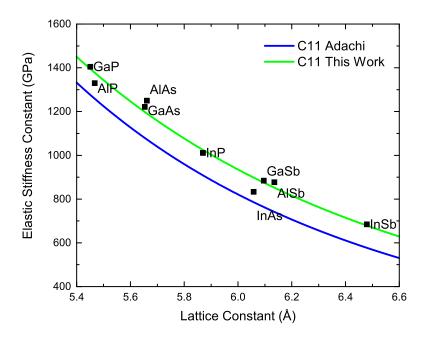


Figure 3: Experimental elastic stiffness constants C_{11} from [1] with fits by [3] and this work using values in Table 1 and Equation 3

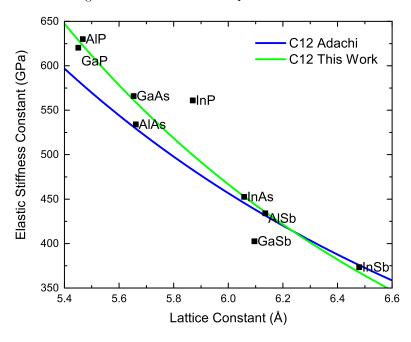


Figure 4: Experimental elastic stiffness constants C_{12} from [1] with fits by [3] and this work using values in Table 1 and Equation 3

Table 1: Equation 3 Coefficients from Adachi [3] and This Work

C_{ij}	α (Adachi)	α (This Work)	β (Adachi)	β (This Work)
C_{11}	-4.59	-4.166	10.33	9.701
C_{12}	-2.54	-3.105	6.07	7.104

5 Strain Compensation Thickness

5.1 Continuum Elasticity Theory (CET, QD Height as QW)

Theory to compensate the strain of quantum wells was developed by Ekins-Daukes *et al.* [4], and an explicit Equation (4) for the required strain compensation thickness based on this work was presented by Bailey *et al.* [5].

$$t_{SC} = t_{QW} \frac{A_{QW} a_{SC}^2 (a_{sub} - a_{QW})}{A_{SC} a_{OW}^2 (a_{SC} - a_{sub})}$$
(4)

Here, t is a layer thickness in Å, a is a lattice constant in Å, and the subscripts SC, QW, and sub represent the strain compensation material, the quantum well material, and the substrate material, respectively. A is a constant material parameter based on stiffness constants, described in Equation 5, where i represents the appropriate material system based on the previous set of subscripts.

In the software, these Equations are used to calculate the required strain compensation thickness for CET (QD Height as QW) and as part of Modified CET (QD as Cylinder), though the specifics of the latter are described in the next section.

For CET (QD Height as QW), the software takes the calculated material parameters, based on the user's selection, and calculates the required thickness to compensate the strain of a quantum well with a thickness equal to what the user entered into the QD Height field. The fields QD Diameter, QD Density, and WL Thickness are not used in this calculation. Consequently, the Effective QD + QL Thickness is identically equal to the QD Height.

$$A_i = C_{11,i} + C_{12,i} - \frac{2C_{12,i}^2}{C_{11,i}} \tag{5}$$

5.2 Modified Continuum Elasticity Theory (mCET, QD as Cylinder)

Bailey et al. went on to modify the CET to include 3D quantum dots by introducing a weighting factor based on QD density, height, and diameter to compensate both the portion of a QD layer which is a wetting layer (WL) and that which is QDs [5]. This method ultimately treats the QD as a cylinder, and the WL as a QW with cylinder-voids based on the density of QDs.

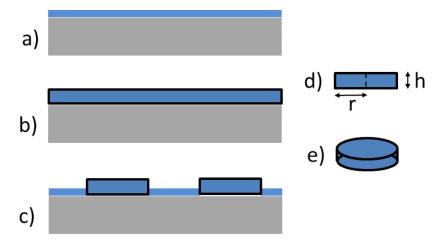


Figure 5: Visualization of the source of strain compensation calculation thickness using the modified CET presented by Bailey *et al.* (cylinder). a) Wetting layer thickness, b) QD thickness expanded to a QW, c) QD and WL thicknesses weighted by QD density, d) diagram of QD and e) 3D perspective.

Two strain compensation layer thicknesses are calculated, based on Equations 4 and 5: the first to compensate just the WL thickness (as a whole QW, Figure 5a) denoted $t_{SC,WL}$, and the second to compensate the QD (as a QW with the thickness equal to the height of the QD, Figure 5b), denoted $t_{SC,QD}$. These thicknesses are then weighted by the fractional areal density of QDs (Figure 5c), denoted by the product of ρ , the 2D density of QDs and σ , the cross-sectional area of the base of a single QD, calculated as the area of a circle with a diameter equal to the QD diameter. This effectively treats the QDs as cylinders (Figures 5d,e) with a volume shown by Equation 6. The full method of calculating strain compensation thickness is shown in Equation 7. It is worth being explicit here that this method treats the QD and WL as non-overlapping entities.

$$V_{QD} = \pi r^2 h \tag{6}$$

$$t_{SC,weighted} = \rho \sigma t_{SC,QD} + (1 - \rho \sigma) t_{SC,WL} \tag{7}$$

For Modified CET (QD as Cylinder), the software takes the calculated material parameters, based on the user's selection, and calculates the required thickness to compensate the strain of a $\mathrm{QD}+\mathrm{WL}$ system based on the values entered in QD Height, QD Diameter, QD Density, and WL Thickness. The volume of a single QD is shown in QD Vol(Cylinder) and the effective coverage of all QD material is shown in Effective QD + WL Thickness.

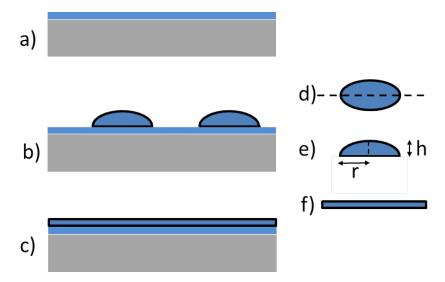


Figure 6: Visualization of the source of strain compensation calculation thickness using the modified CET presented in this work (oblate-hemispheroid). a) Wetting layer thickness, b) QDs on top of the wetting layer, c) QD thickness expanded to a QW, d) diagram of oblate spheroid with center line, e) diagram of QD and e) QD volume averaged over an area creating an effective thickness.

5.3 Modified Continuum Elasticity Theory (mCET, QD as Oblate-Hemispheroid)

This work introduces an alternate method of determining effective QD thickness: treating the QD as half of an oblate spheroid, with a volume shown in Equation 8. This method is similar to the weighted CET process described by Bailey et al. (see previous section) but treats the QD and the WL as overlapping entities. Again using Equations 4 and 5, one strain compensation layer thickness is calculated for the WL (Figure 6), and second a SC thickness is calculated for the effective QD thickness. This effective thickness averages the volume of a QD (as a half oblate spheroid) against the QD density through multiplication as shown in Equation 9. Figure 6d shows the origin of the shape, with Figure 6e giving the parameters, and Figure 6f showing the effective QD thickness multiplied by density. Figures 6b-c show the evolution of how QDs are treated in this system, ultimately giving a complete QD material effective thickness.

$$V_{QD} = \frac{\frac{4\pi}{3}r^2h}{2}$$
 (8)

$$t_{QD} = \frac{\frac{4\pi}{3}r^2h}{2}\sigma\tag{9}$$

For Modified CET (QD as Oblate-Hemispheroid), the software takes the

calculated material parameters, based on the user's selection, and calculates the required thickness to compensate the strain of a $\mathrm{QD} + \mathrm{WL}$ system based on the values entered in QD Height, QD Diameter, QD Density, and WL Thickness. The volume of a single QD is shown in QD Vol(Obl. Sph.) and the effective coverage of all QD material is shown in Effective $\mathrm{QD} + \mathrm{WL}$ Thickness.

5.4 Comparison of QD Volume Calculation Methods

Leonard et al. first described the volume of a single QD as a spherical cap [6], as shown in Equation 10. A visual explanation of this is shown in Figure 7. This volume determination is not used in any of the methods of calculating strain compensation thicknesses, and is included only for interest.

$$V_{QD} = \frac{\pi h}{6} (3r^2 + h^2) \tag{10}$$

Comparison of the spherical cap method to the oblate-hemispheroid method is shown in Figure 8. Over a size range typically encountered in physical QDs (height ≤ 5 nm, diameter ≥ 10 nm), these methods differ by $\sim 28\%$. However, in a realm where a spherical cap no longer makes much sense (e.g.: height > diameter), the spherical cap method begins to differ dramatically from the oblate-hemispheroid method (shown in Figure 8) and the cylinder method, which is why it is not used anywhere in this software for strain compensation thickness calculations.

The percent difference between the cylinder volume and the oblate hemispheroid volume is geometric and equal to exactly 50% – a cylinder has 50% more volume than an oblate hemispheroid given the same radius and height.

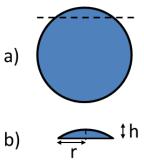


Figure 7: QD shape made by the cap (b) of a sphere (a) as reported by Leonard et al. [6]

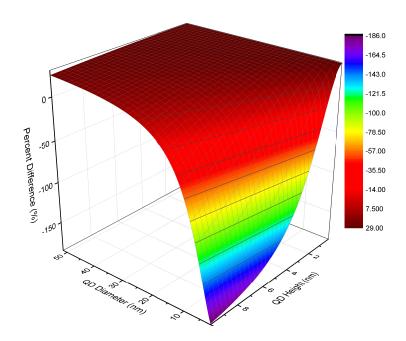


Figure 8: Percent difference between the volumes of QDs made from spherical caps and oblate hemispheroids as a function of QD diameter and height.

References

- [1] I. Vurgaftman, J. R. Meyer, and L. R. Ram-Mohan, "Band parameters for III-V compound semiconductors and their alloys", *Journal of Applied Physics*, vol. 89, no. 11, pp. 5815–5875, Jun. 1, 2001, ISSN: 00218979. DOI: 10.1063/1.1368156.
- [2] S. Adachi, "Band gaps and refractive indices of AlGaAsSb, GaInAsSb, and InPAsSb: key properties for a variety of the 2-4-μm optoelectronic device applications", Journal of Applied Physics, vol. 61, no. 10, pp. 4869–4876, May 15, 1987, ISSN: 0021-8979, 1089-7550. DOI: 10.1063/1.338352.
- [3] —, Properties of group-IV, III-V and II-VI semiconductors. Chichester, England; Hoboken, NJ: John Wiley & Sons, 2005, ISBN: 9780470090329. DOI: 10.1002/0470090340.
- [4] N. J. Ekins-Daukes, K. Kawaguchi, and J. Zhang, "Strain-balanced criteria for multiple quantum well structures and its signature in x-ray rocking curves†", *Crystal Growth & Design*, vol. 2, no. 4, pp. 287–292, Jul. 1, 2002, ISSN: 1528-7483. DOI: 10.1021/cg025502y.
- [5] C. G. Bailey, S. M. Hubbard, D. V. Forbes, and R. P. Raffaelle, "Evaluation of strain balancing layer thickness for InAs/GaAs quantum dot arrays using high resolution x-ray diffraction and photoluminescence", Applied Physics Letters, vol. 95, no. 20, Nov. 2009, ISSN: 0003-6951. DOI: 10.1063/1.3264967.
- [6] D. Leonard, K. Pond, and P. M. Petroff, "Critical layer thickness for self-assembled InAs islands on GaAs", *Physical Review B*, vol. 50, no. 16, pp. 11687–11692, Oct. 15, 1994. DOI: 10.1103/PhysRevB.50.11687.